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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10027519	FILING DATE 12/20/2001	CLASS 438	SUBCLASS 758	GAU 2825	EXAMINER YEVS/KOV
**APPLICANTS: Li Li;					
**CONTINUING DATA VERIFIED: yes V.Y. THIS APPLICATION IS A CON OF 09/388,570 09/02/1999 now patent # 6,395,647					
** FOREIGN APPLICATIONS VERIFIED: none V.Y.					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no		35 USC 119 conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no		ATTORNEY DOCKET NO	
Verified and Acknowledged Examiners's initials V.Yevs/Kov V.Y.				MICRON.106C1	
TITLE : Chemical treatment of semiconductor substrates					

U.S. DEPT. OF COMM./PAT. & TM.-PTO-435L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.
		Print Fig.	
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
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